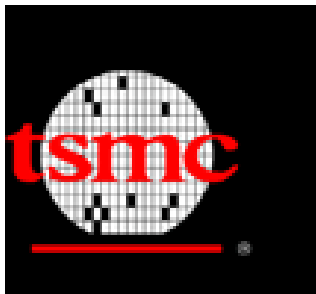


Tailoring Electronic Coupling in Single-Crystal Bilayer Graphene

NCKU (July 5, 2012)

Po-Wen Chiu

Department of Electrical Engineering
National Tsing Hua University



工業技術研究院

Industrial Technology
Research Institute



行政院國家科學委員會
National Science Council

National Tsing Hua University



Particularly thanks the hard-working group members...



Also Dr. Kazu Suenaga...



Outline

1. About graphene growth...

- CVD graphene
- CVD graphene without grain boundaries

2. About bilayer graphene ...

- Tailoring a twist in bilayer
- TEM + Raman technique
- Coupling or decoupling?

First graphene growth on Ni

1970-1980. Jack Blakely and team: Graphene Growth on Metals*

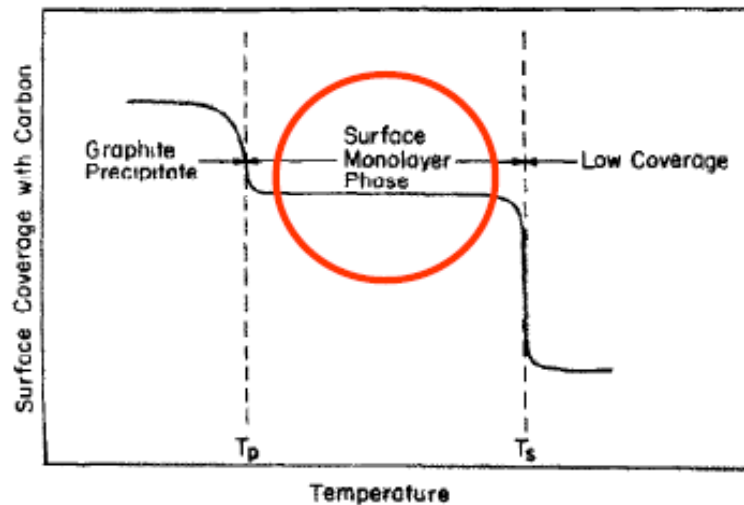
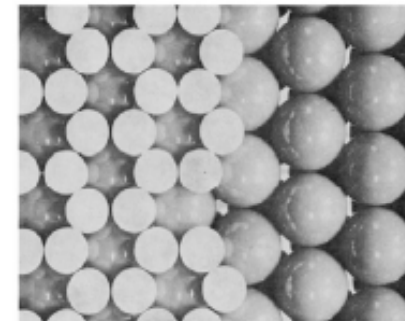


Fig. 1. Schematic equilibrium temperature dependence of carbon coverage on the (111) surface of a carbon doped nickel single crystal. A phase transition from a low coverage to a condensed state occurs at the segregation point T_s ; graphite precipitation starts at T_p .



Ball model of a graphite(001) layer on the (111) surface of Ni. The left hand portion of the photograph depicts the probable arrangement in state II with (001)graphite ||(111)Ni; ||[110]graphite ||[110]Ni. Note that the graphite layer has two atoms per unit mesh.

Graphitic carbon monolayer formation by surface segregation on Ni (111),(110),(311); Pd (100),(111); Co (0001).

Shelton JC, Patil HR, Blakely JM. *Surf. Sci.* 43:493 (1974); Eizenberg M and Blakely JM. *J. Chem. Phys.* 71: 3467 (1979); Eizenberg M and Blakely JM. *Surf.Sci.*, 82:228 (1979); Hamilton JC and Blakely JM. *Surf. Sci.* 91:119 (1980)

***But: Isolation/transfer of graphene from metal substrates onto other substrates is quite recent.** Yu et al. *Appl. Phys. Lett.* 93:113103 (2008); Reina et al. *Nano Lett.* 9:30 (2009); Li et al *Science* 324: 1312-1314 (2009)

First graphene growth on Cu

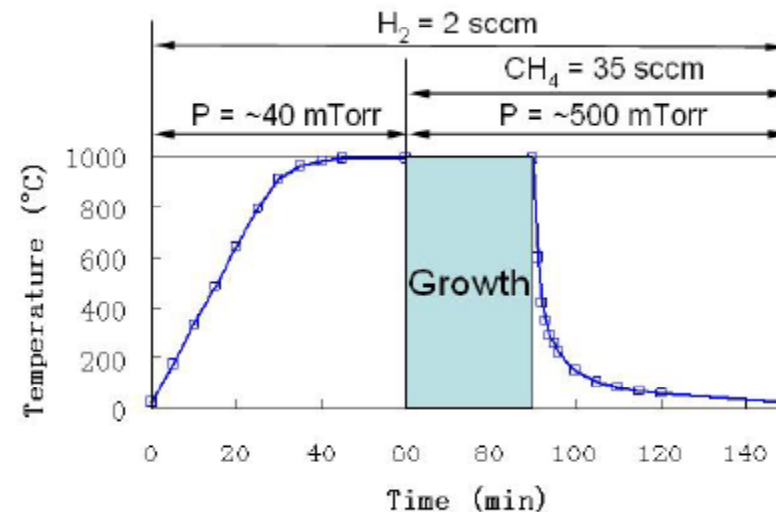
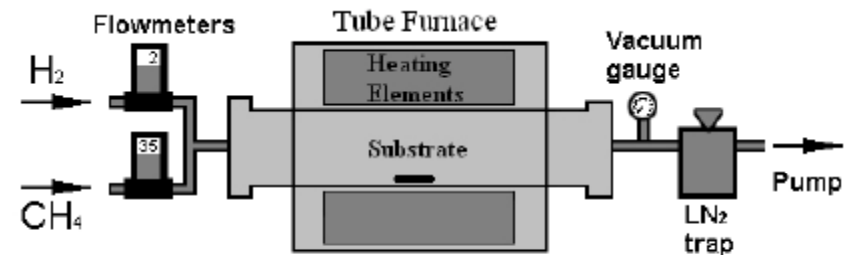
Large-Area Synthesis of High-Quality and Uniform Graphene Films on Copper Foils

Xuesong Li,¹ Weiwei Cai,¹ Jinho An,¹ Seyoung Kim,² Junghyo Nah,² Dongxing Yang,¹ Richard Piner,¹ Aruna Velamakanni,¹ Inhwa Jung,¹ Emanuel Tutuc,² Sanjay K. Banerjee,² Luigi Colombo,^{3*} Rodney S. Ruoff^{1*}

5 JUNE 2009 VOL 324 SCIENCE

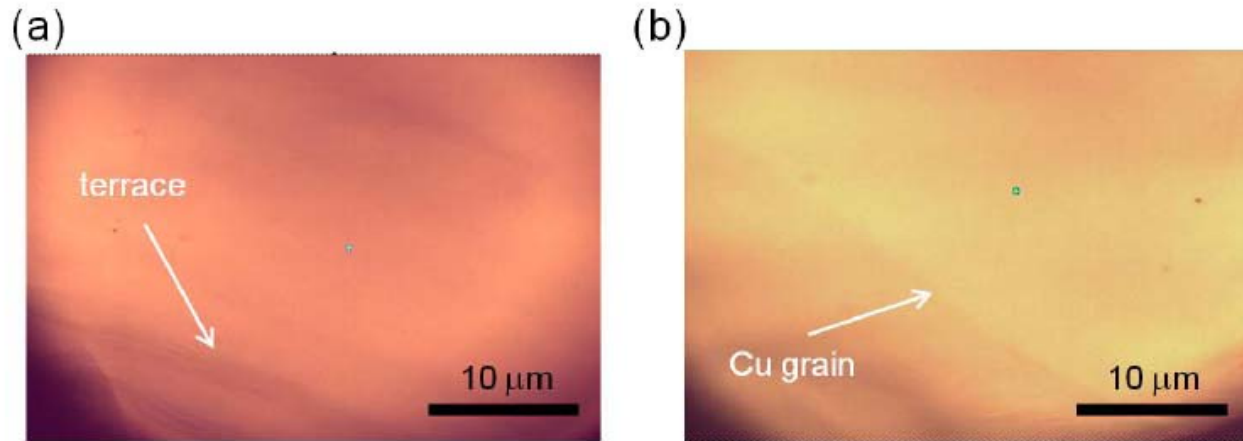
Graphene Growth Process

- 25 μm thick 99.8% pure Cu foil
- Load Cu foil in furnace
- Evacuate furnace
- Heat to $T \sim 1040^\circ\text{C}$ under H_2 gas
- Introduce CH_4 at a flow rate of 35 sccm and $P = 500$ mTorr
- Grow graphene for 1 to 20 min
- Cool to room temperature

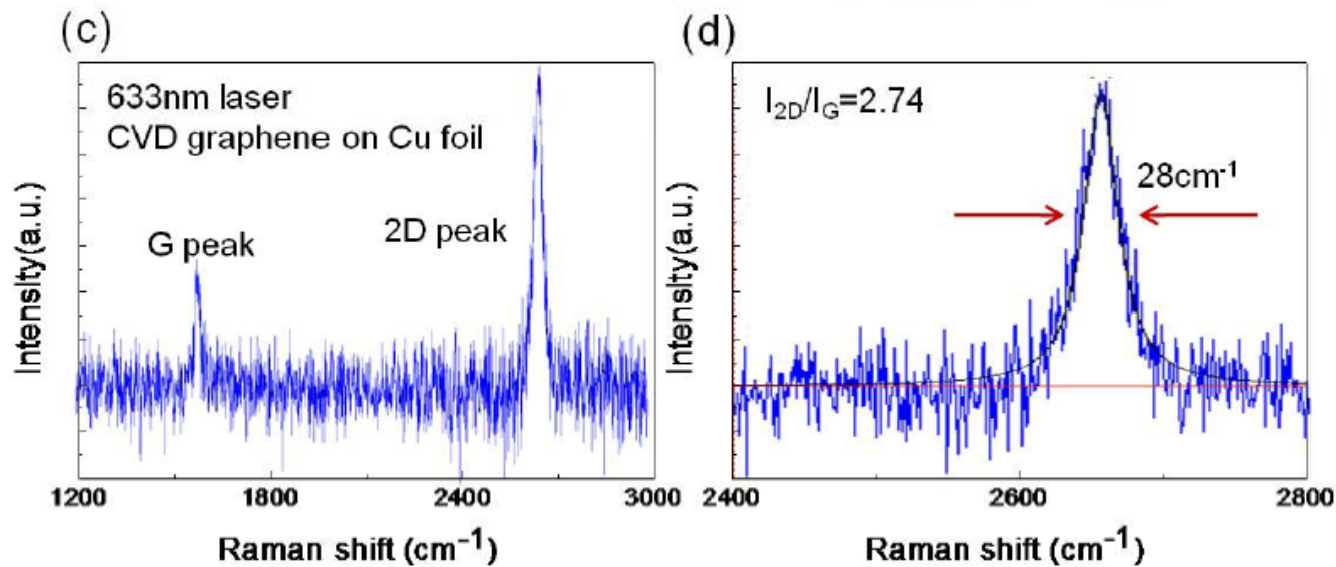
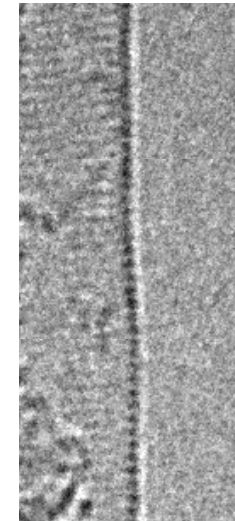


Graphene grown on Cu

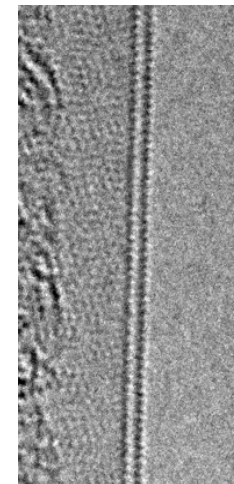
Over 90% of the films is one-layer graphene



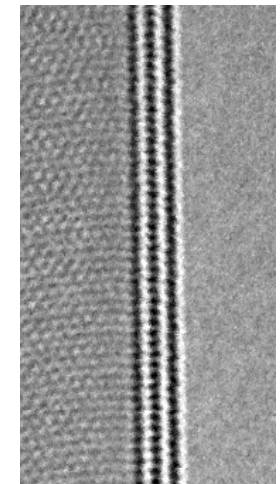
1L



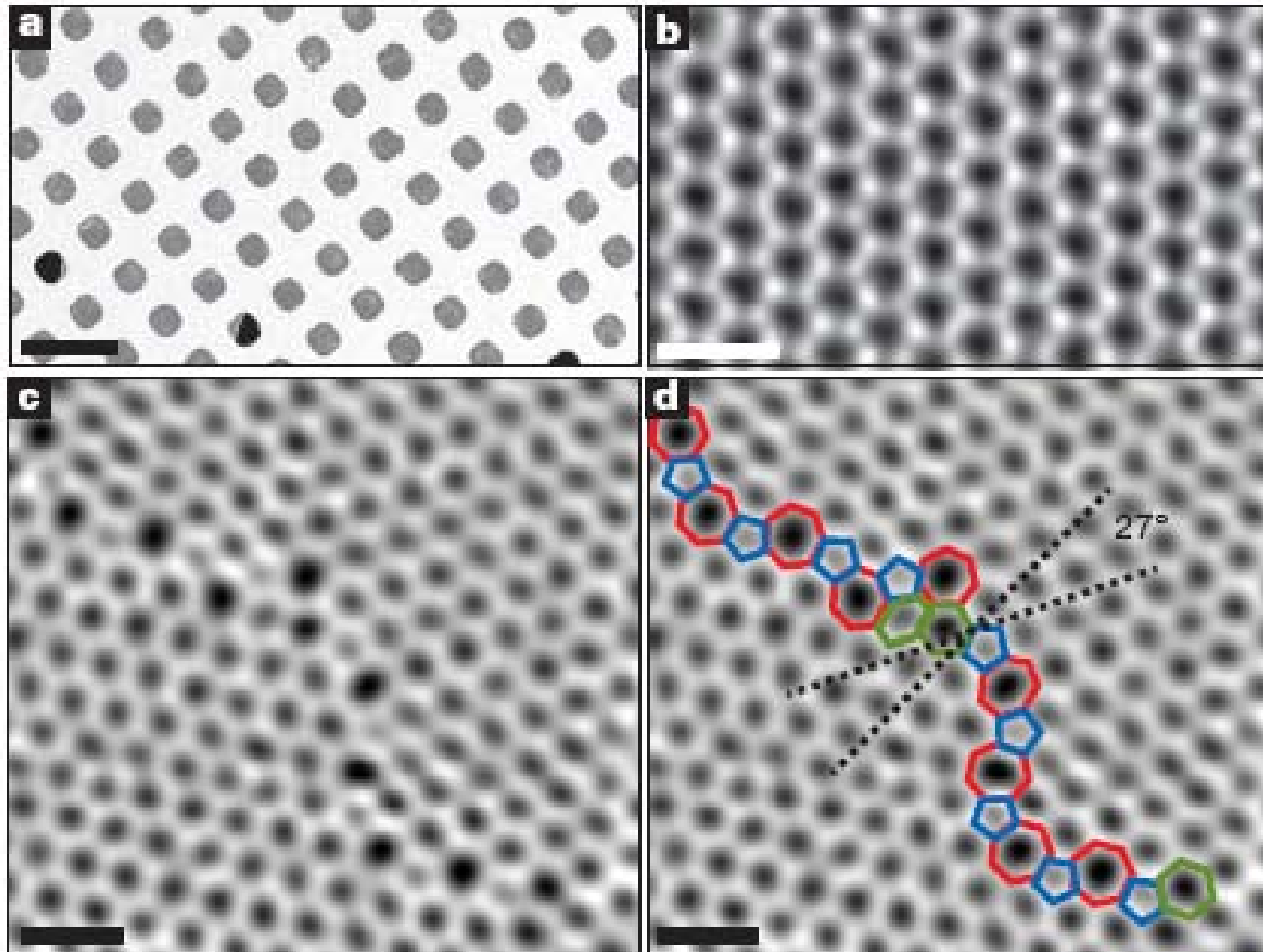
2L



3L



Polycrystalline structure



Control the layer number:

LPCVD

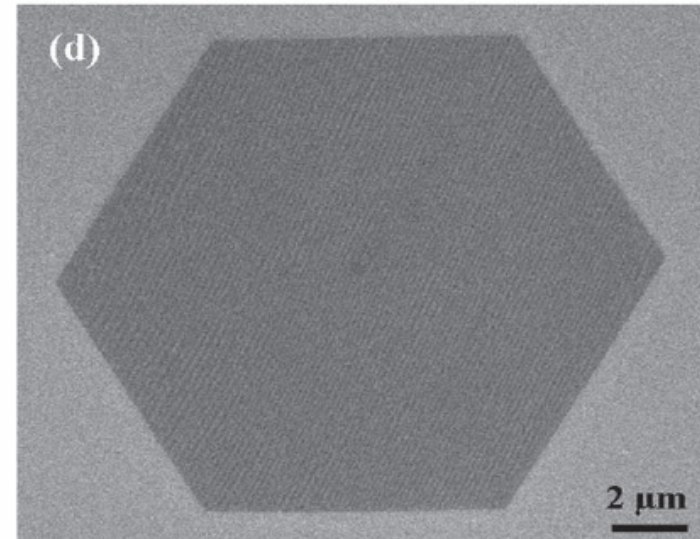
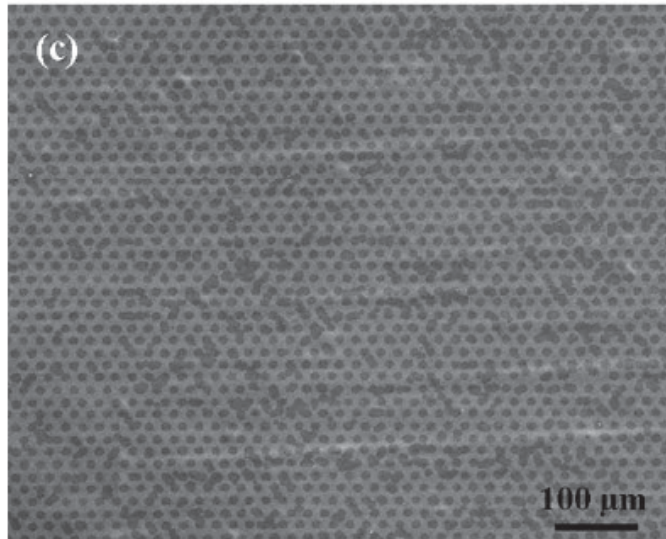
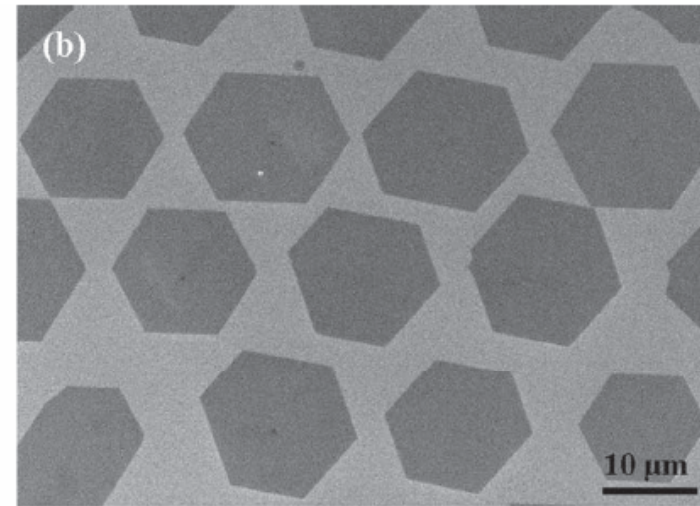
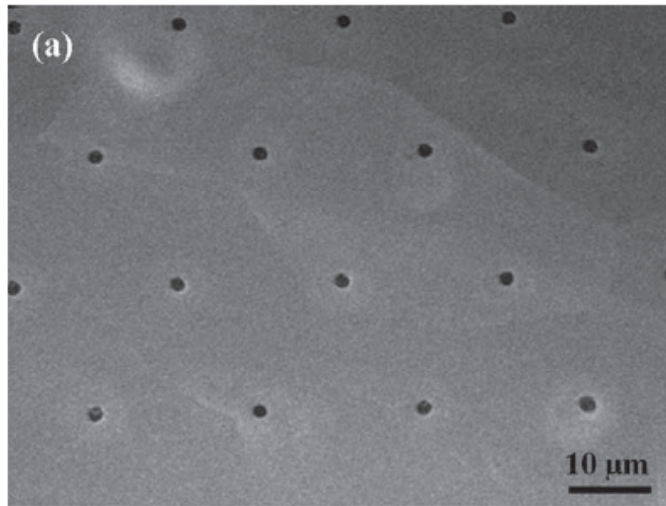
Self-limiting growth

Control the grain size:

APCVD with low C feedstock

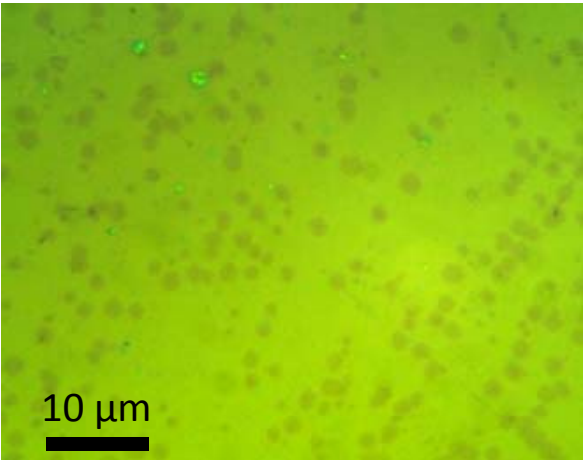
High temperature

Single-crystal graphene on Cu (SEM)

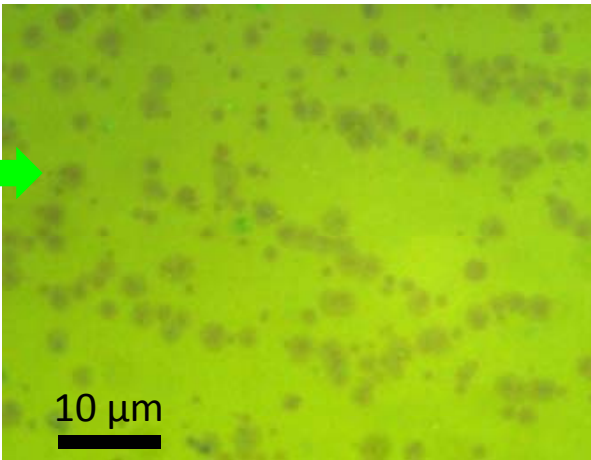


Single-crystal graphene on Cu (OM)

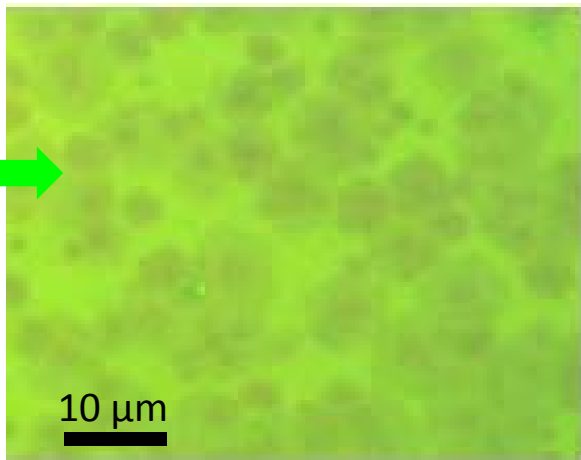
CH4: 1 SCCM
Growth: 3min40sec



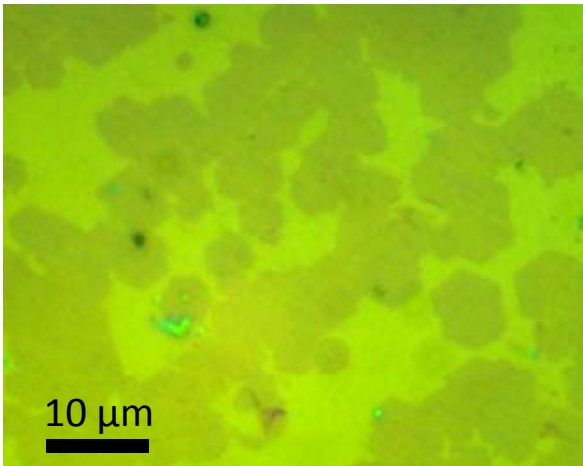
CH4: 1 SCCM
Growth: 4min



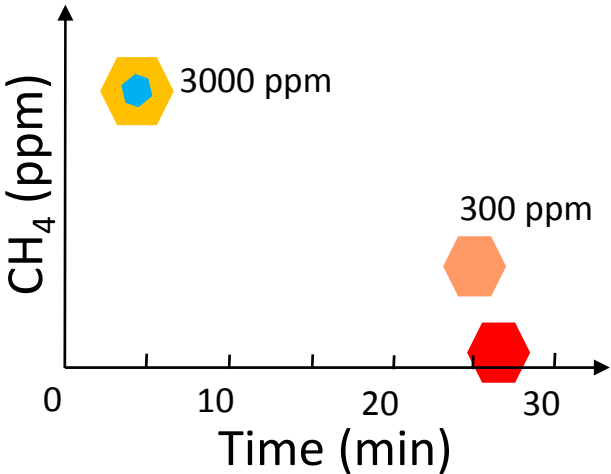
CH4: 1 SCCM
Growth: 4min30sec



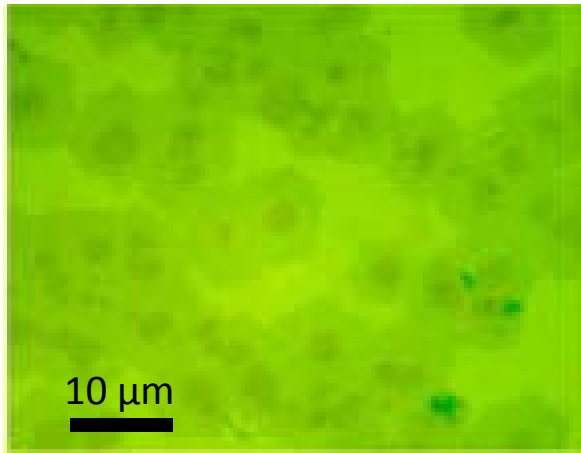
CH4: 0.1 SCCM
Growth: 21min



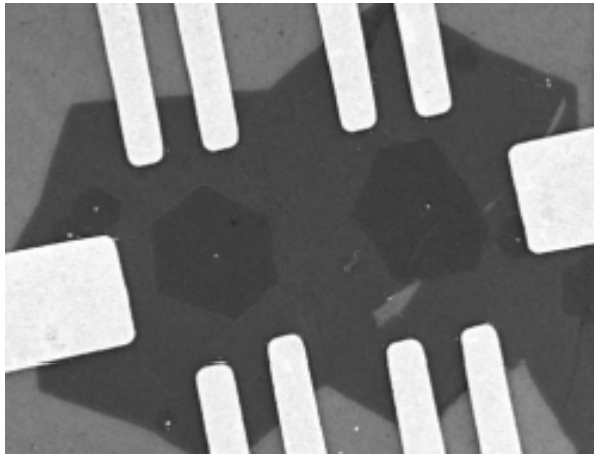
1030 – 1050 °C



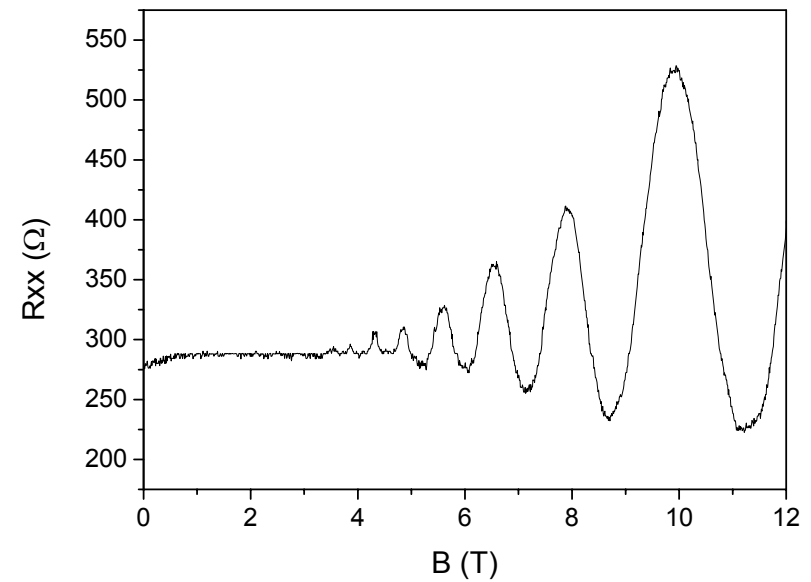
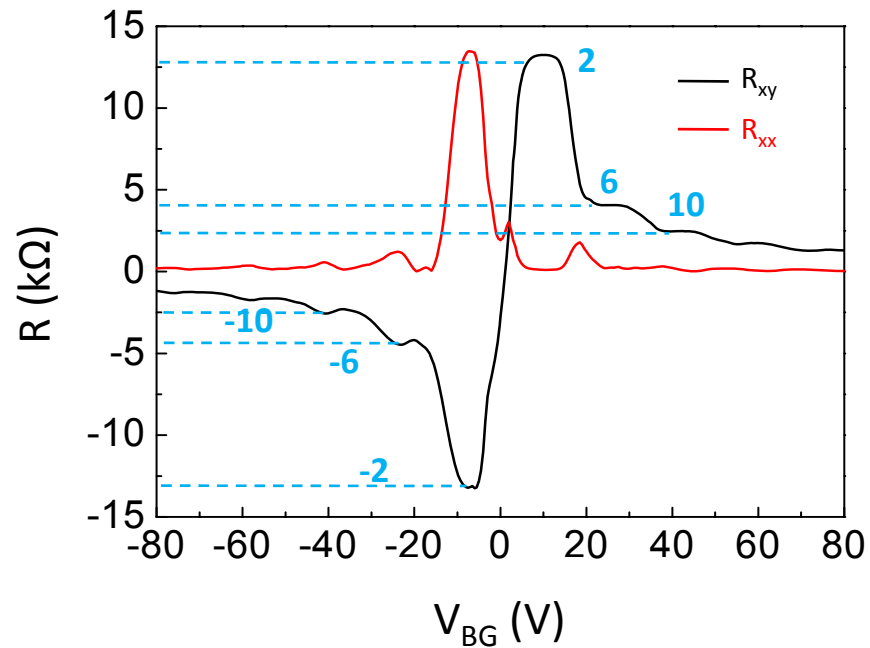
CH4: 1 SCCM
Growth: 5min



Transport properties



Half-integer quantum Hall effect for single layer

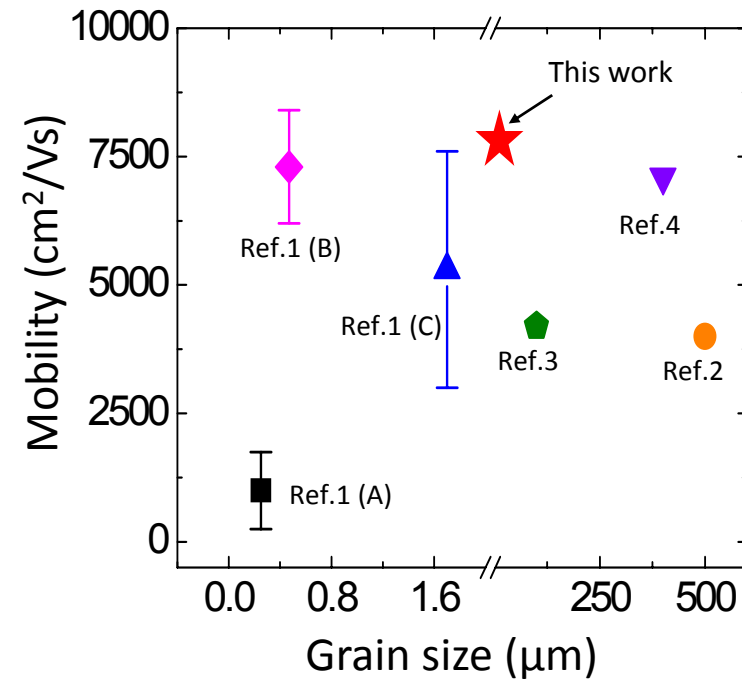
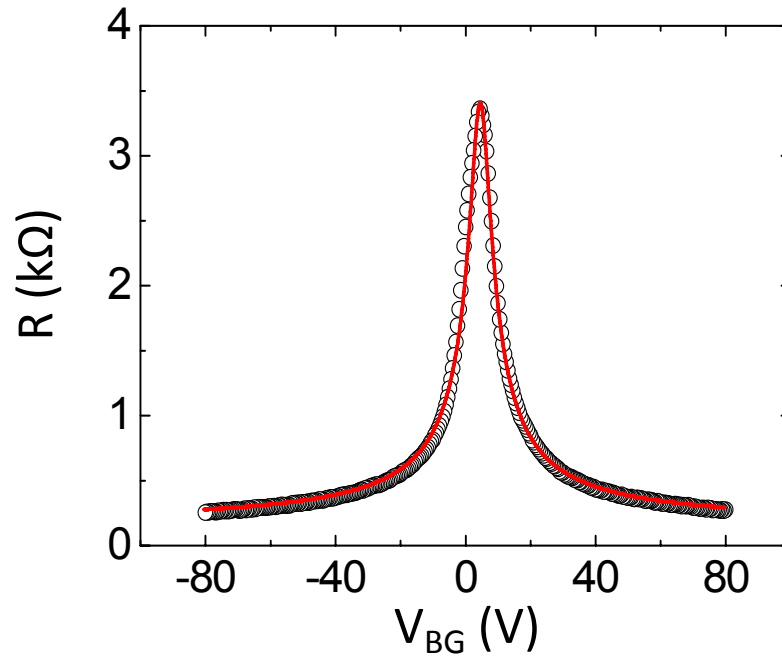


Transport properties

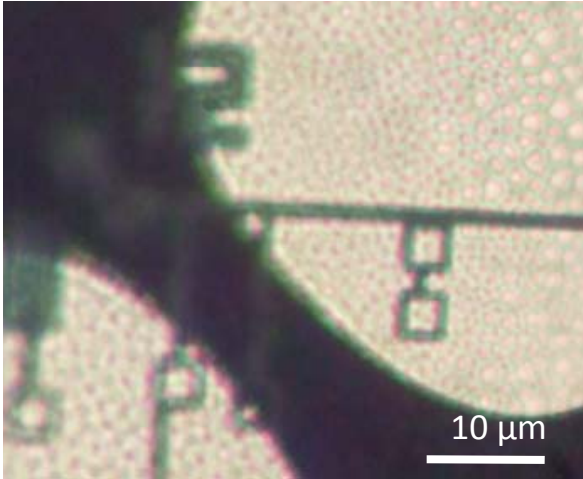
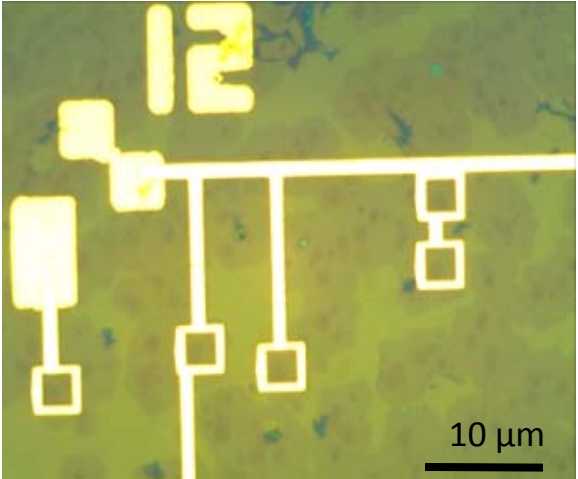
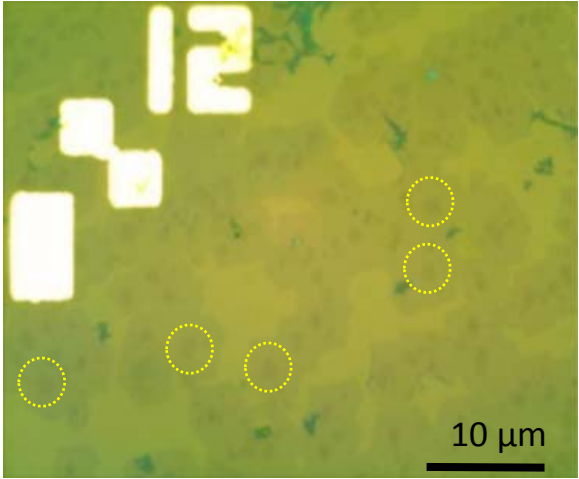
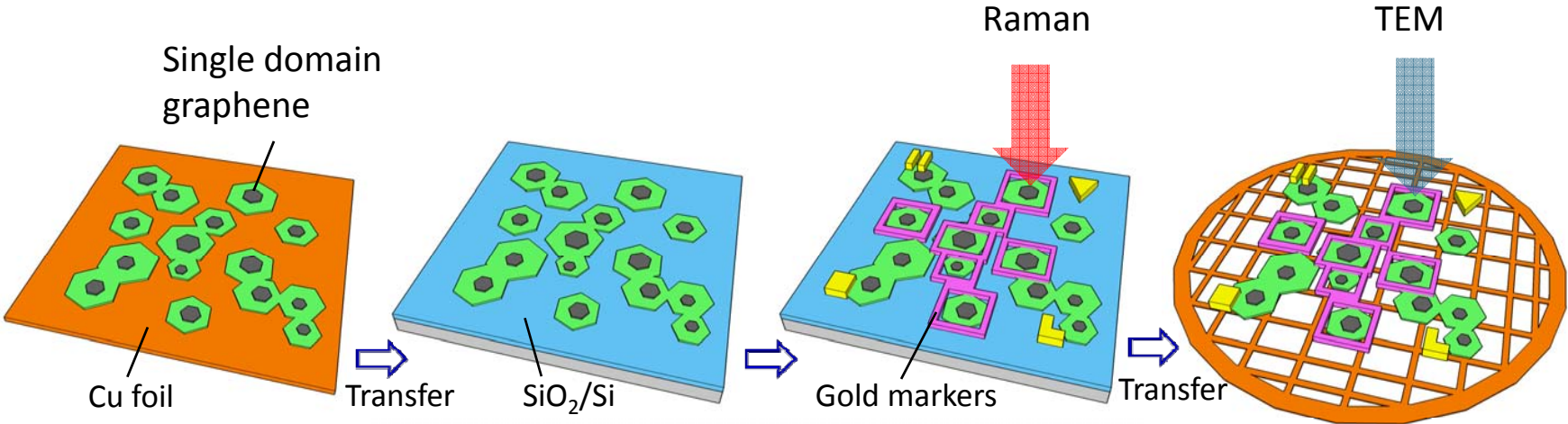
Extra-high mobility compared with other CVD graphene !

mobility = 8000 cm²/Vs

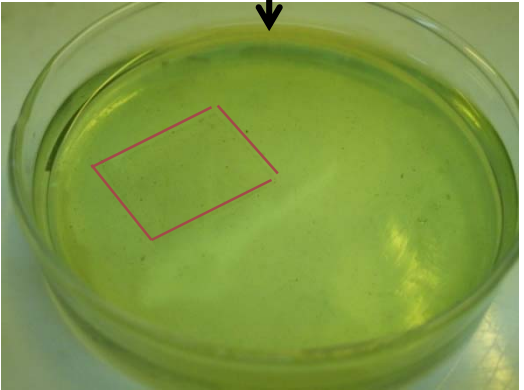
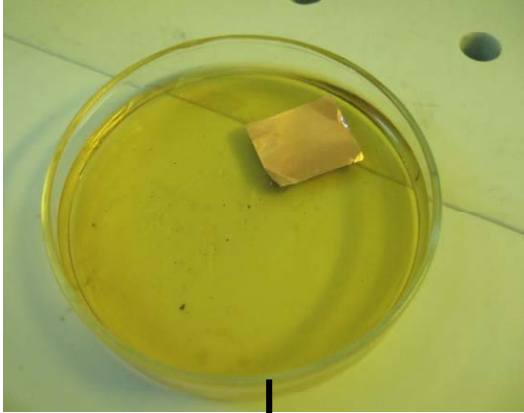
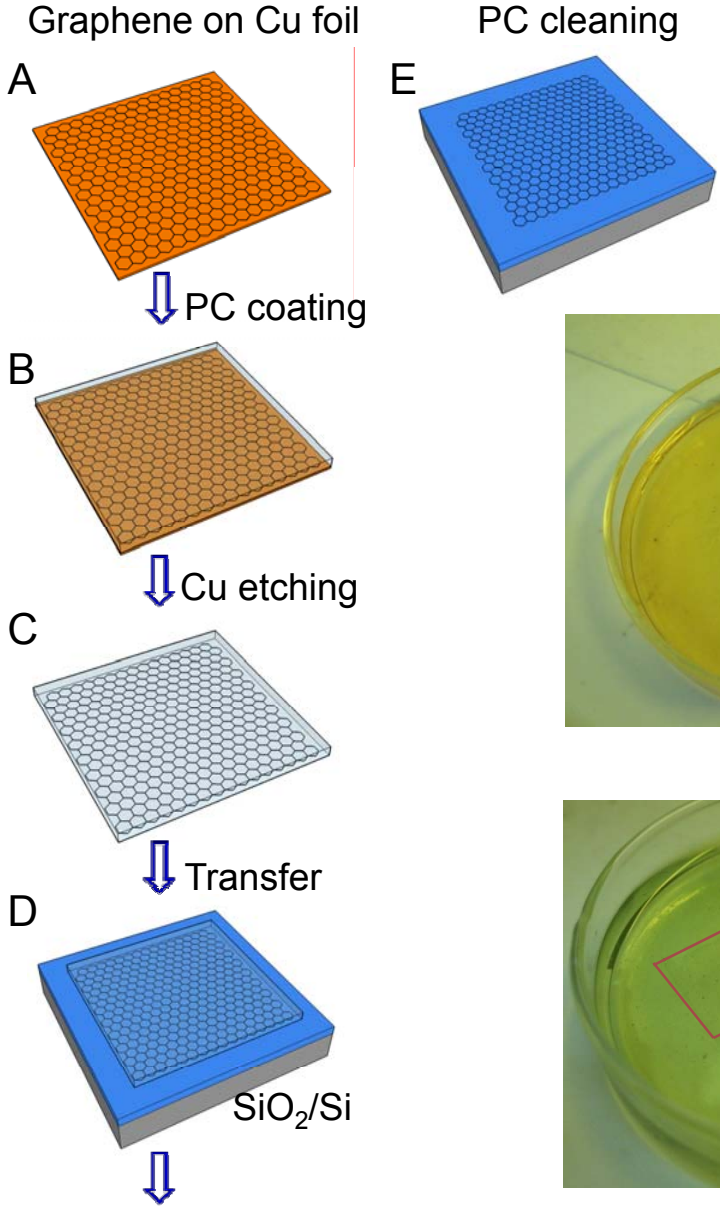
on/off ratio = 12



Raman + TEM

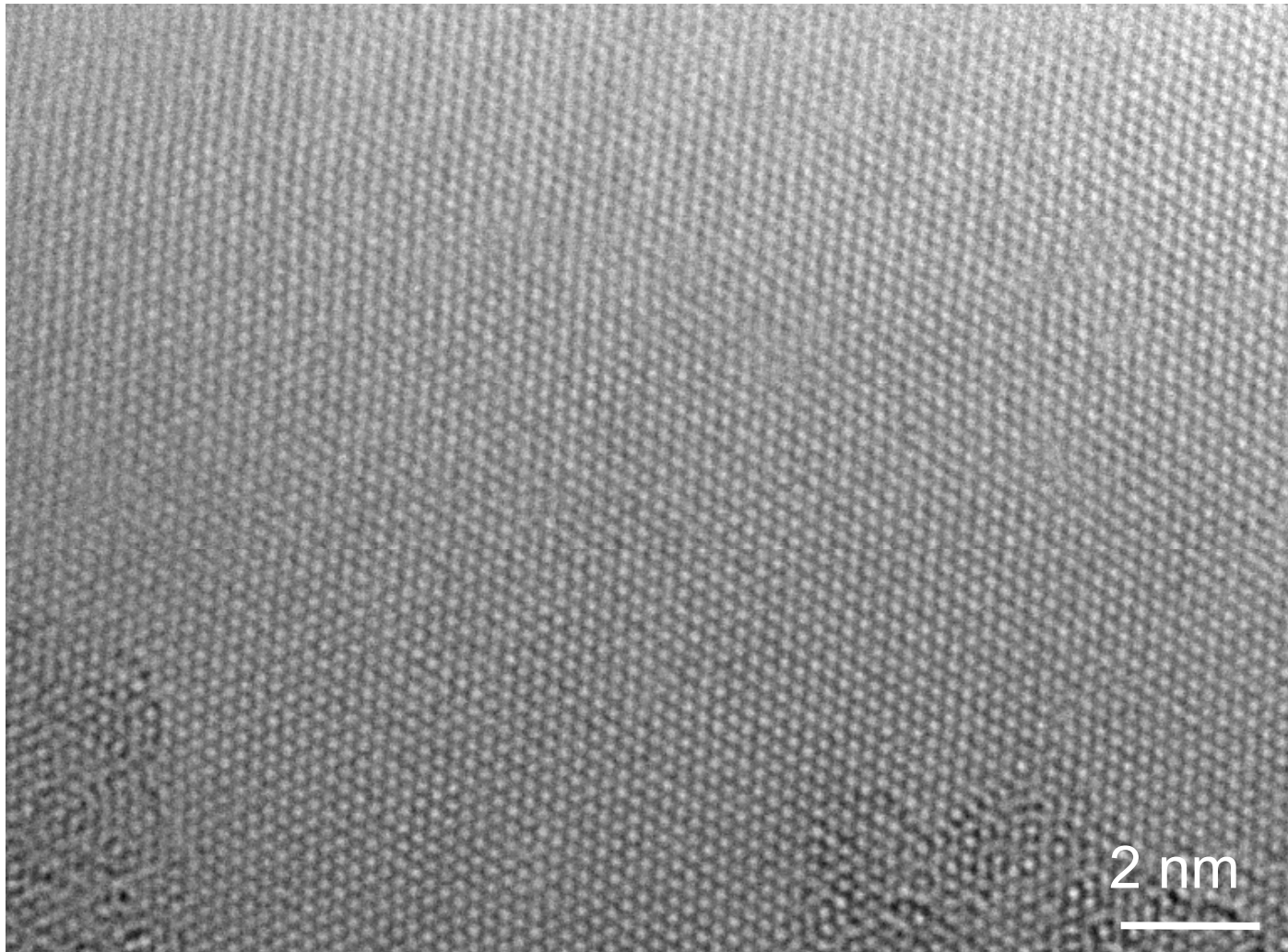


Graphene transfer by PC



Graphene transfer by PC

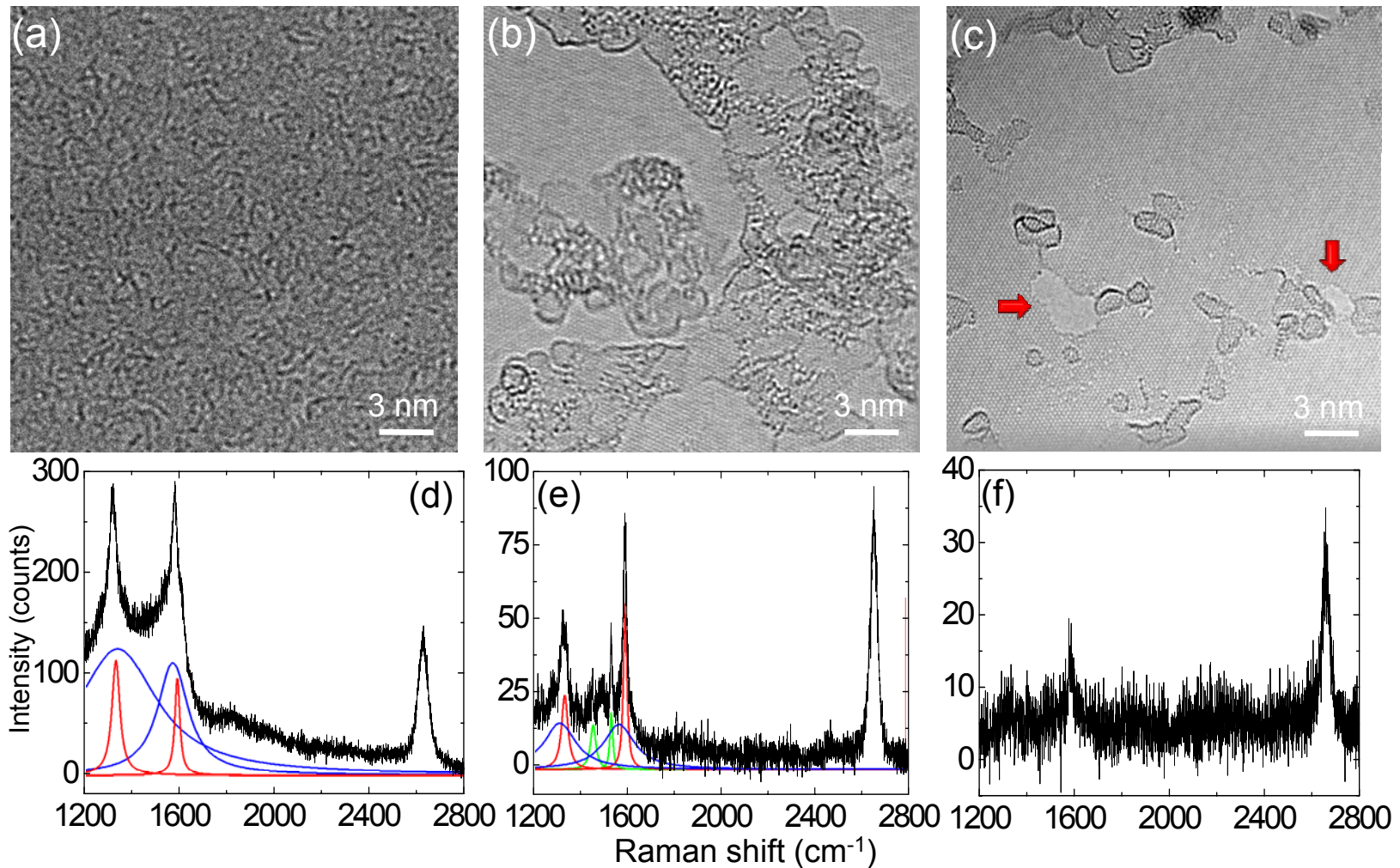
HR-TEM (done in AIST)



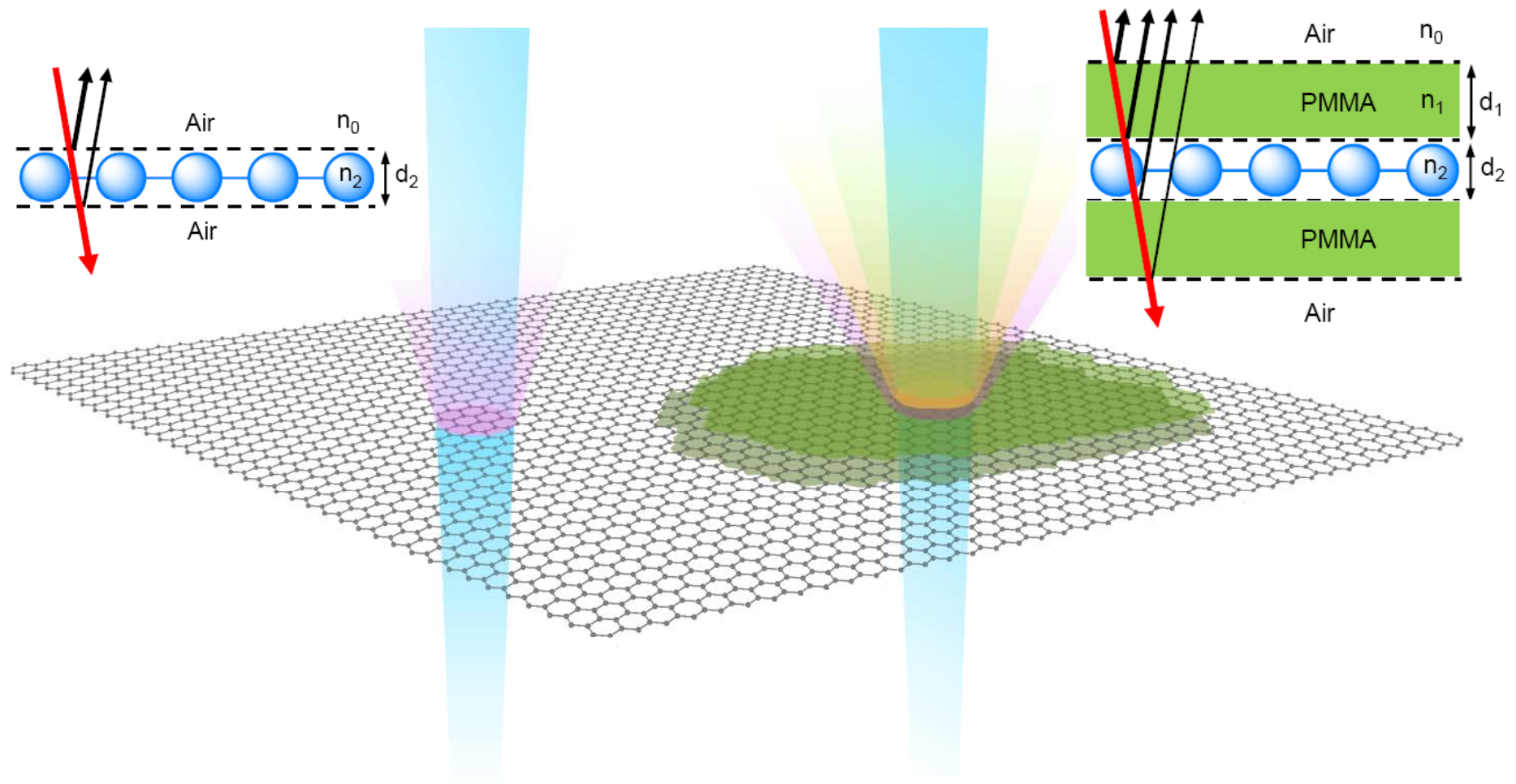
Graphene transfer by PMMA

Always a thin (1-2 nm) layer of PMMA residue on graphene !

Annealing



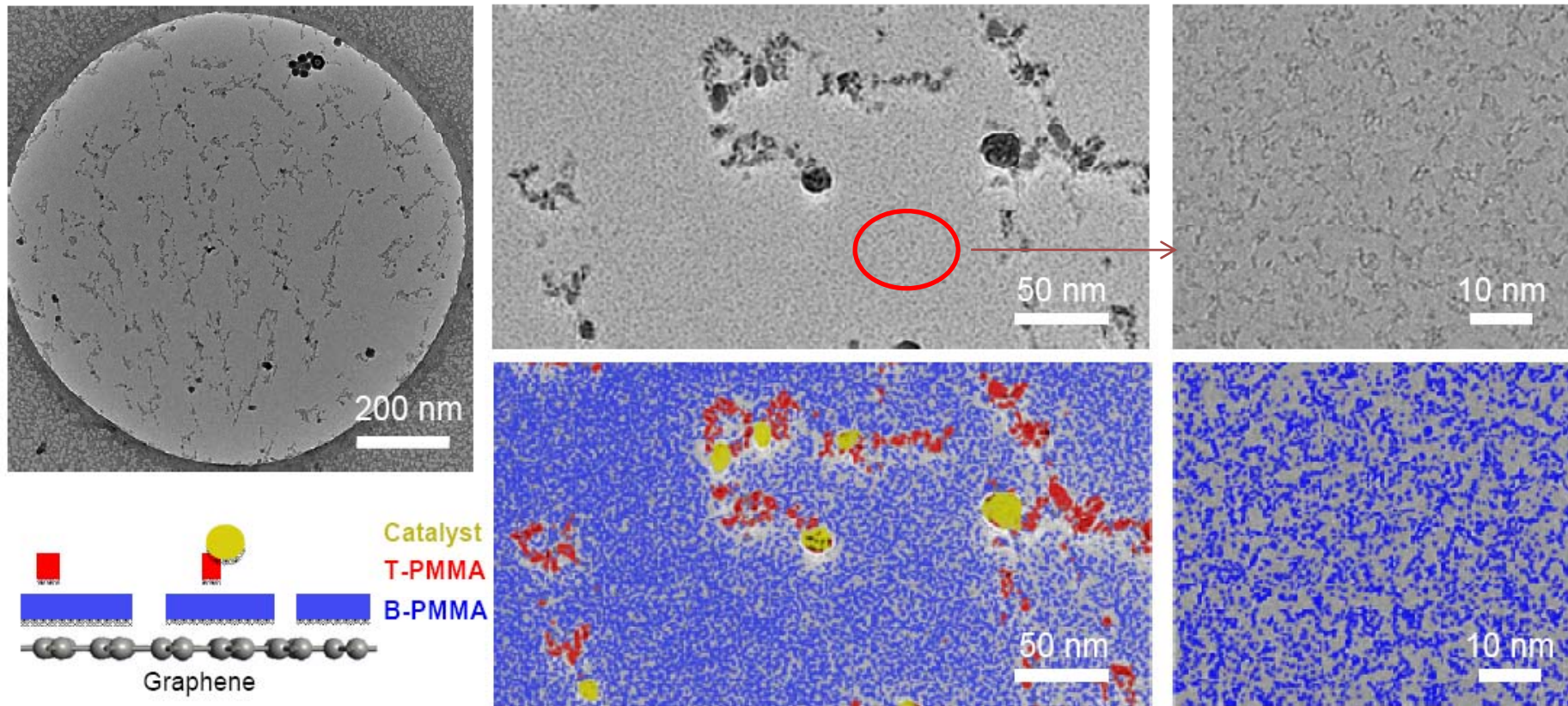
Graphene transfer by PMMA



Y. C. Lin, *et al.*, ACS nano, 5, 2362 (2011)

Mobility reduction due to annealing

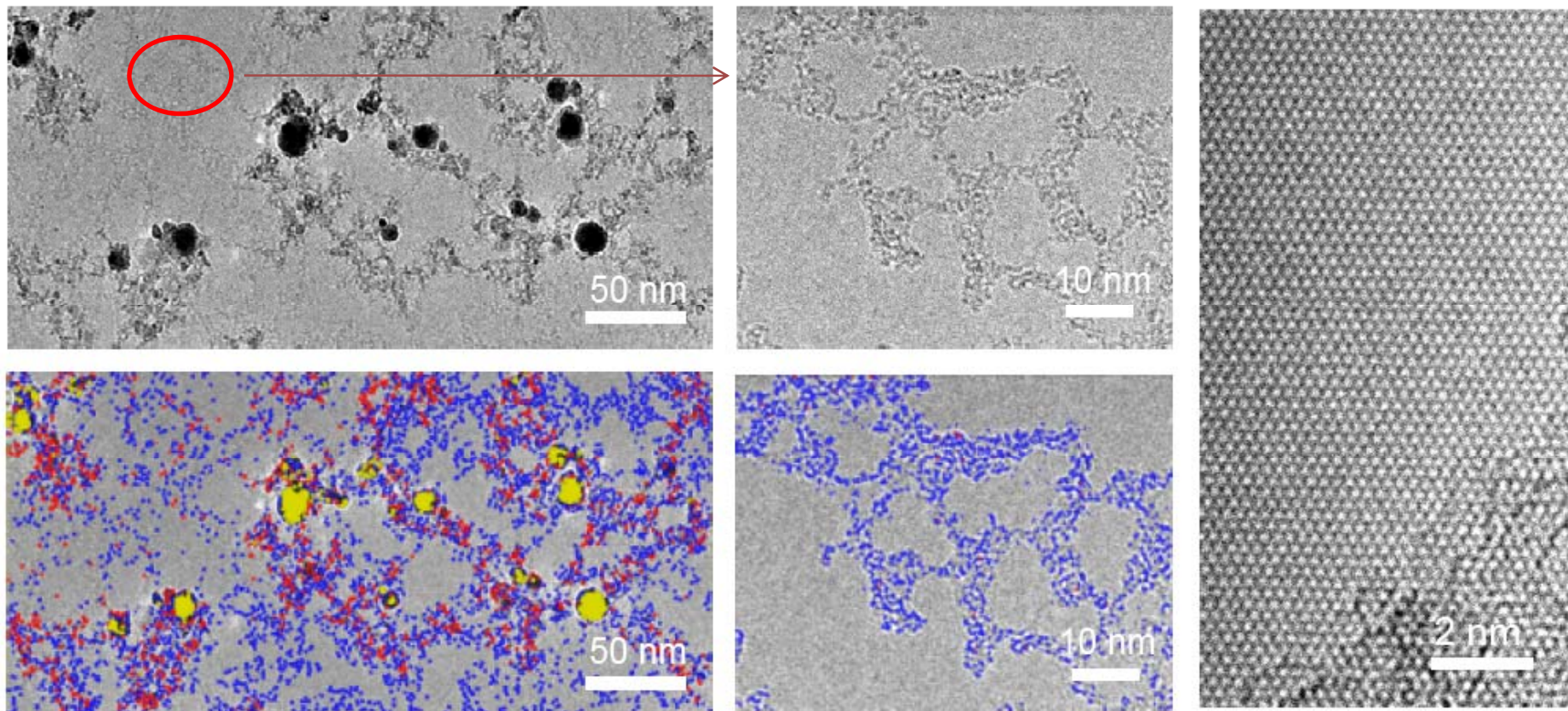
TEM images of graphene annealing at 200 °C



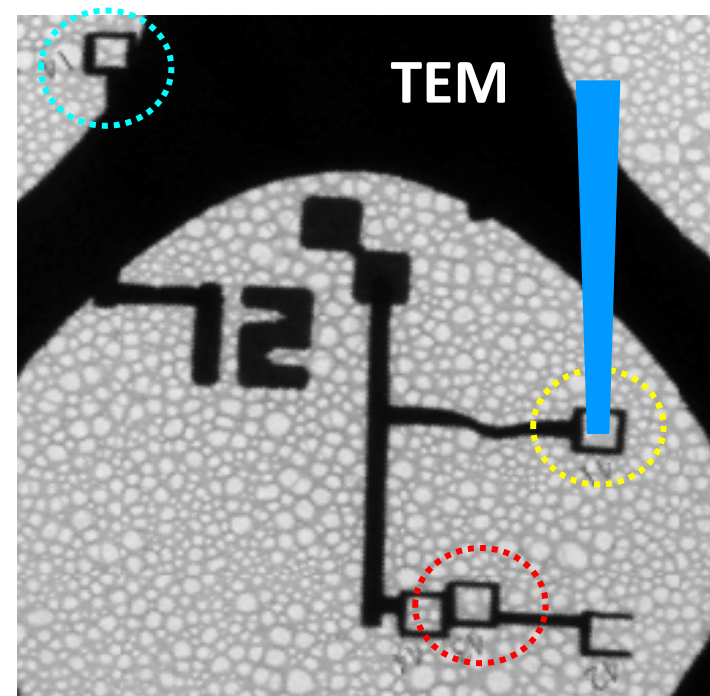
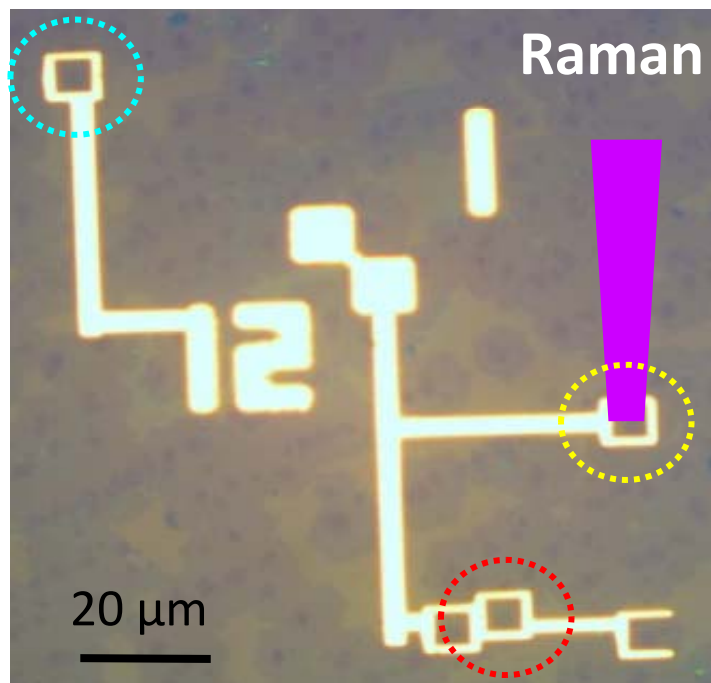
Y. C. Lin, *et al.*, Nano Lett., 12, 414 (2012)

Mobility reduction due to annealing

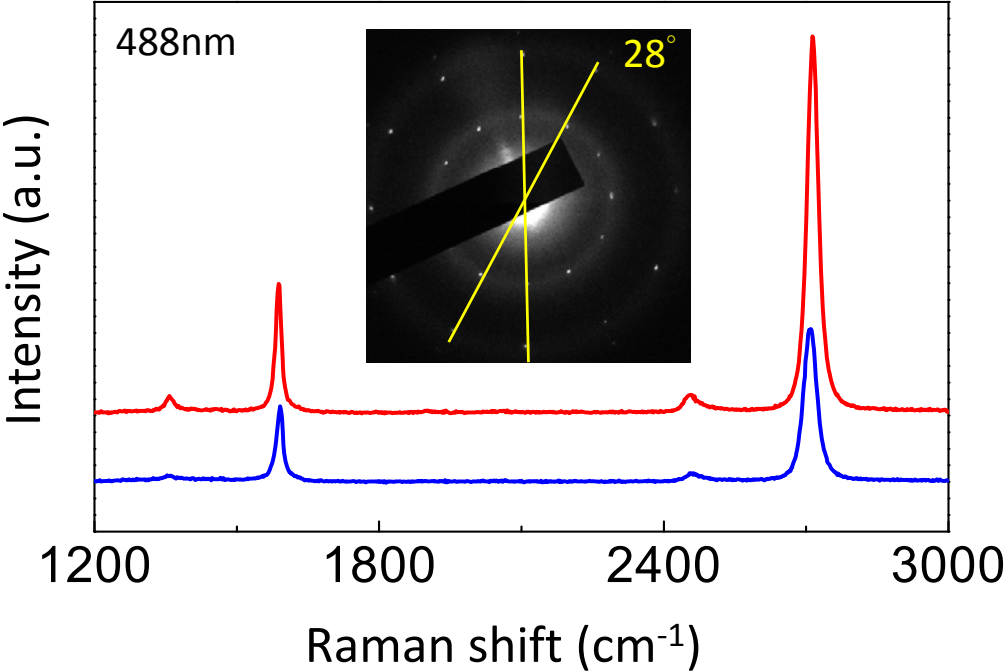
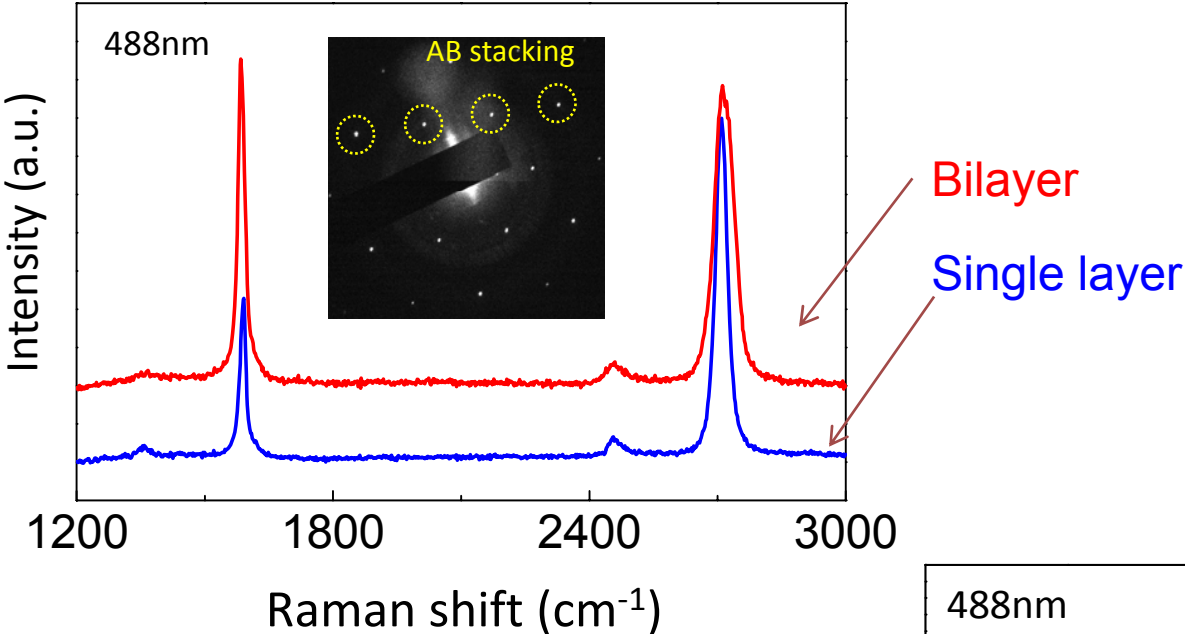
TEM images of graphene annealing at 250 °C



Raman + TEM

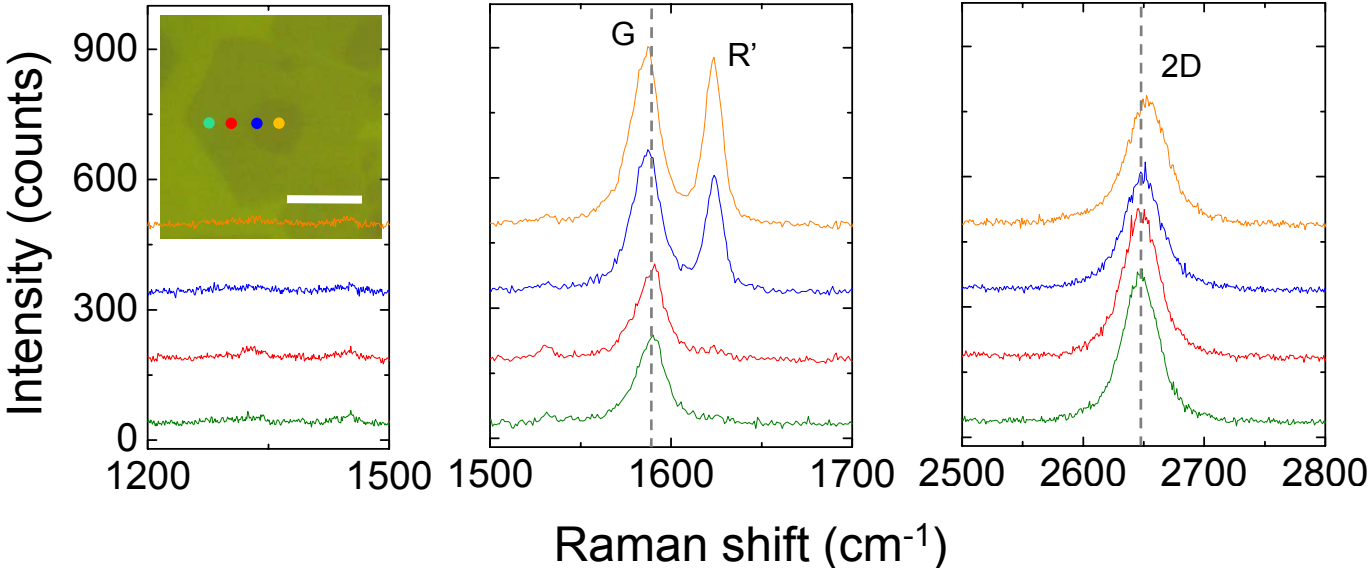


Angle-dependent Raman spectra

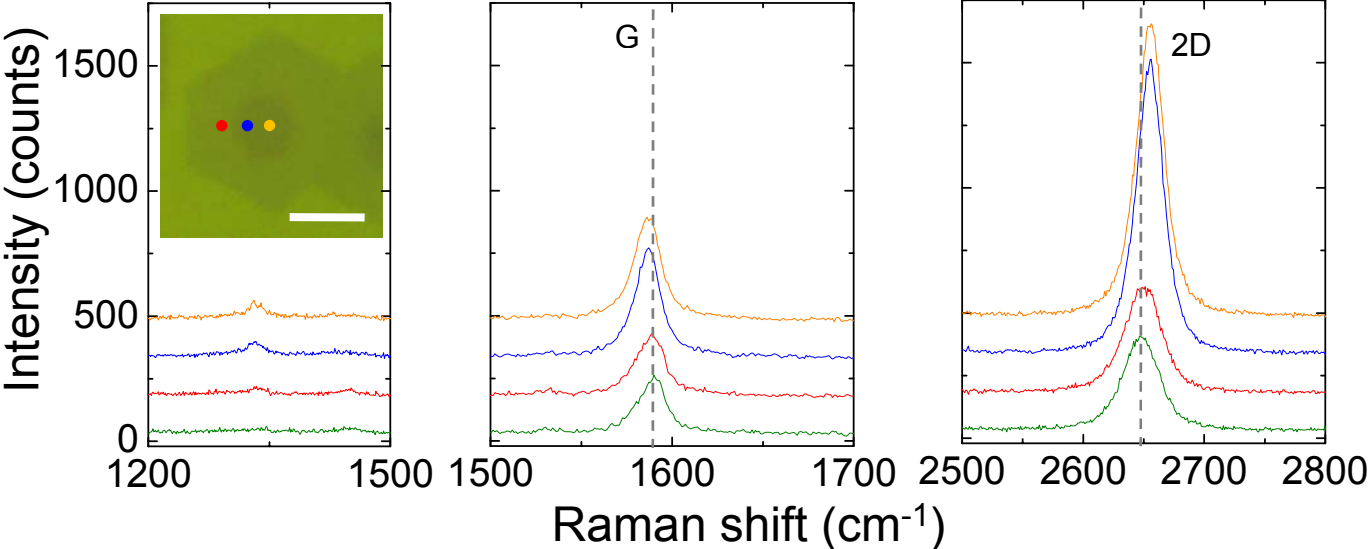


Angle-dependent Raman spectra

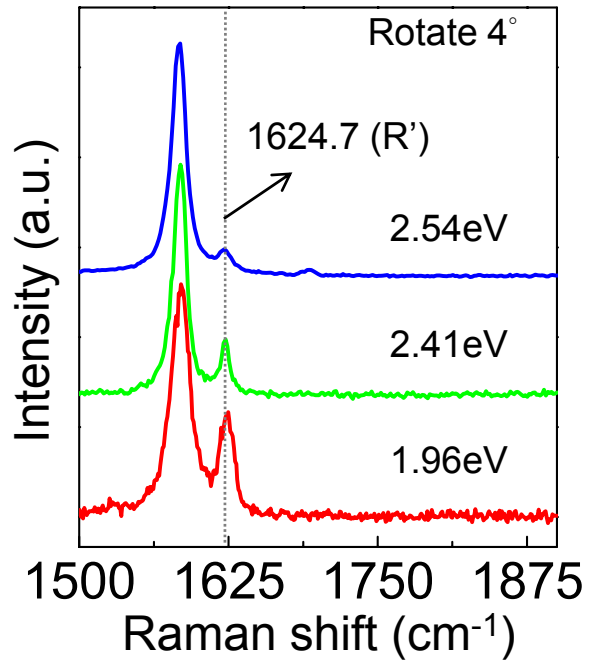
No.12_10_47 (6°)



No.11_11_29 (26°)

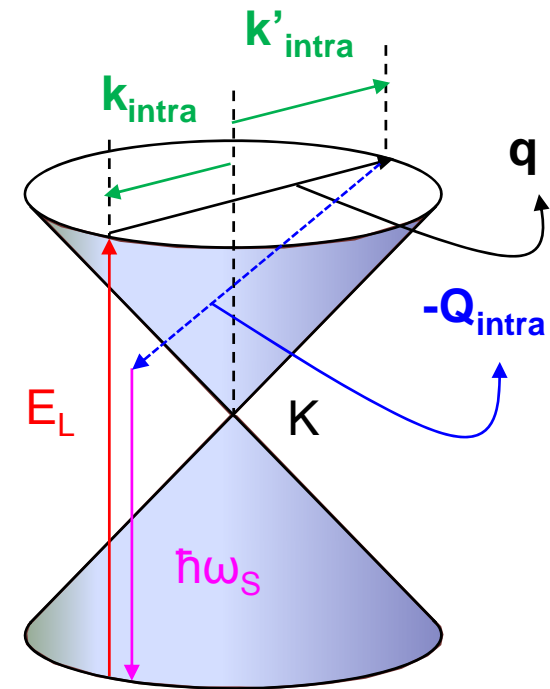
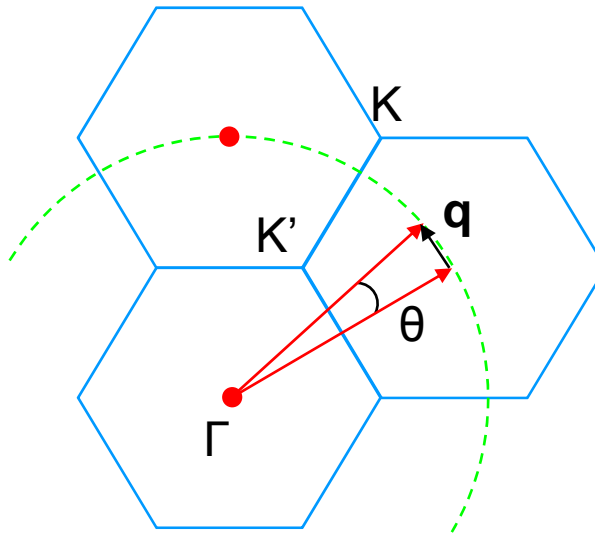


Angle dependent Raman spectra



New Raman feature: R' mode

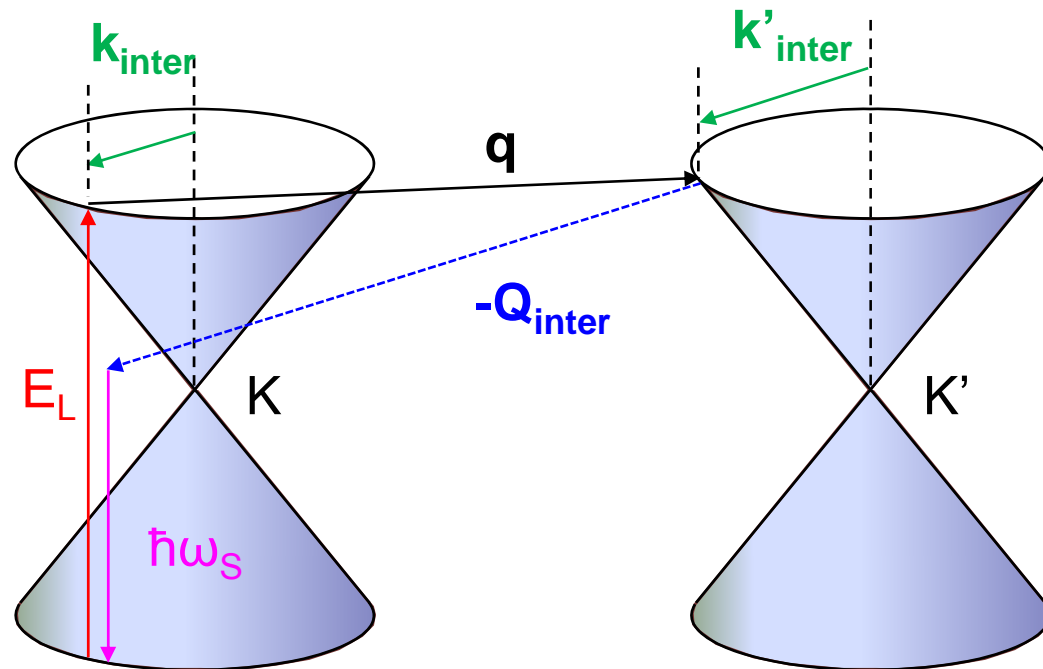
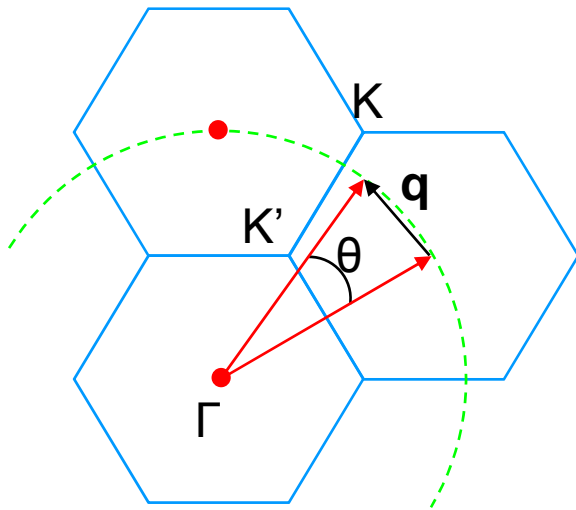
1. non-dispersive
2. intravalley double resonance



Angle-dependent Raman spectra

New Raman feature: R mode

1. non-dispersive
2. intervalley double resonance



Raman Signature of Graphene Superlattices

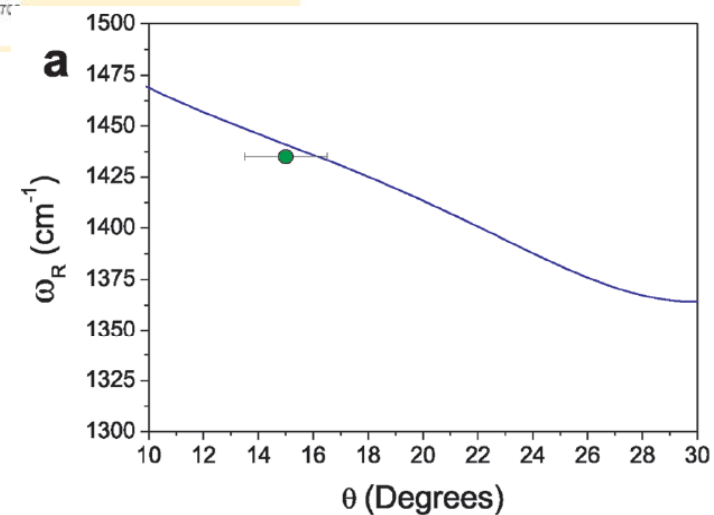
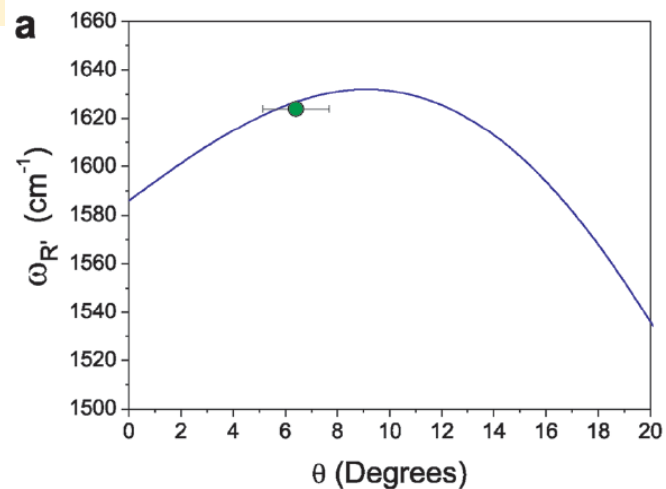
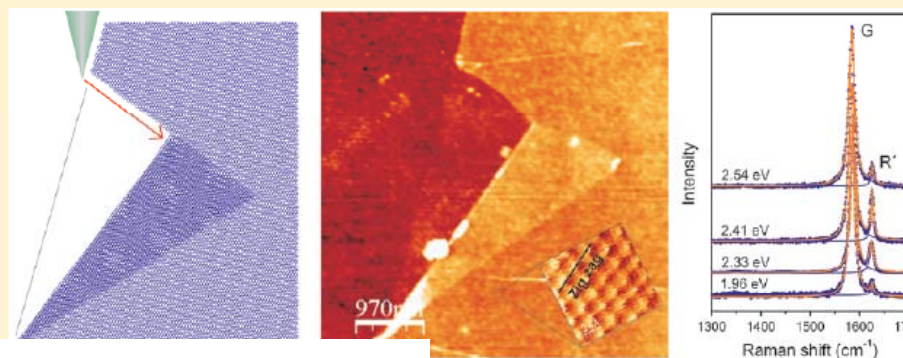
Victor Carozo,^{†,‡} Clara M. Almeida,[‡] Erlon H. M. Ferreira,[‡] Luiz Gustavo Cançado,[§]
 Carlos Alberto Achete,^{†,‡} and Ado Jorio^{*,§}

[†]Departamento de Engenharia Metalúrgica e de Materiais, Universidade Federal do Rio de Janeiro, Rio de Janeiro RJ, 21941-972, Brazil

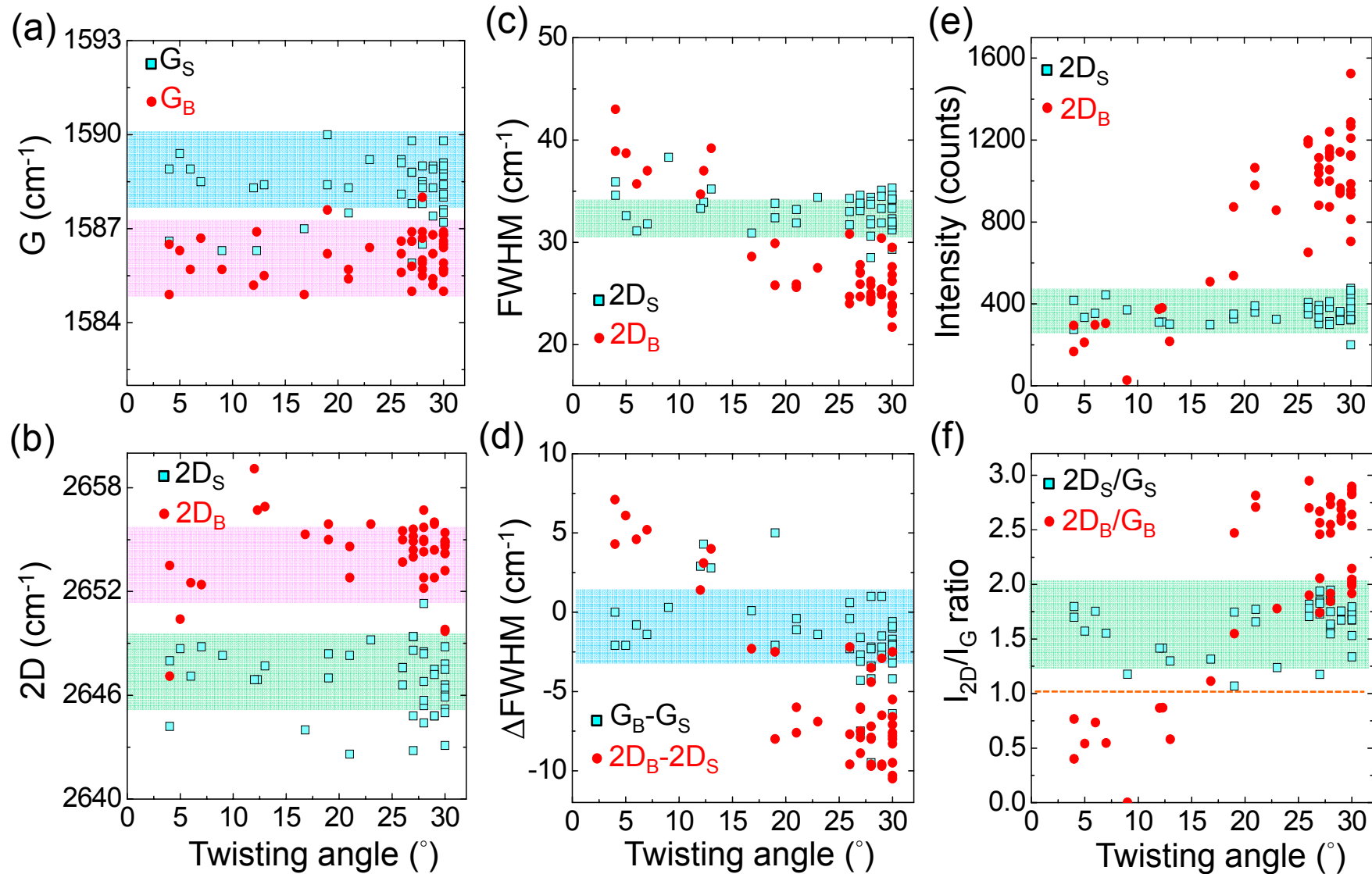
[‡]Divisão de Metrologia de Materiais, Instituto Nacional de Metrologia, Normalização e Qualidade Industrial (INMETRO), Duque de Caxias RJ 25250-020, Brazil

[§]Departamento de Física, Universidade Federal de Minas Gerais, Belo Horizonte MG 30123-970, Brazil

ABSTRACT:

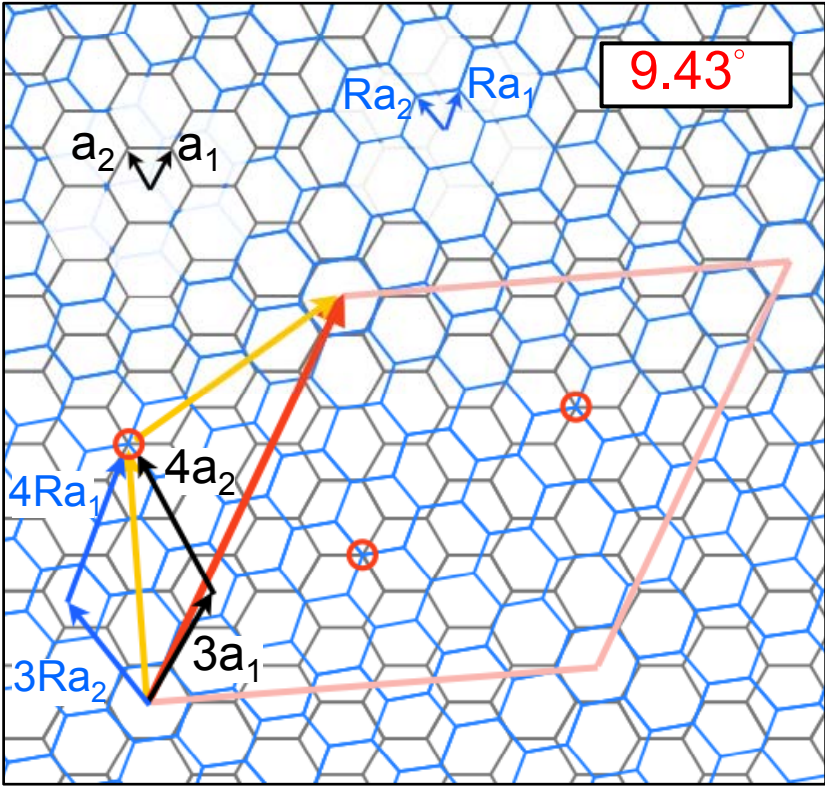


Angle-dependent Raman spectra

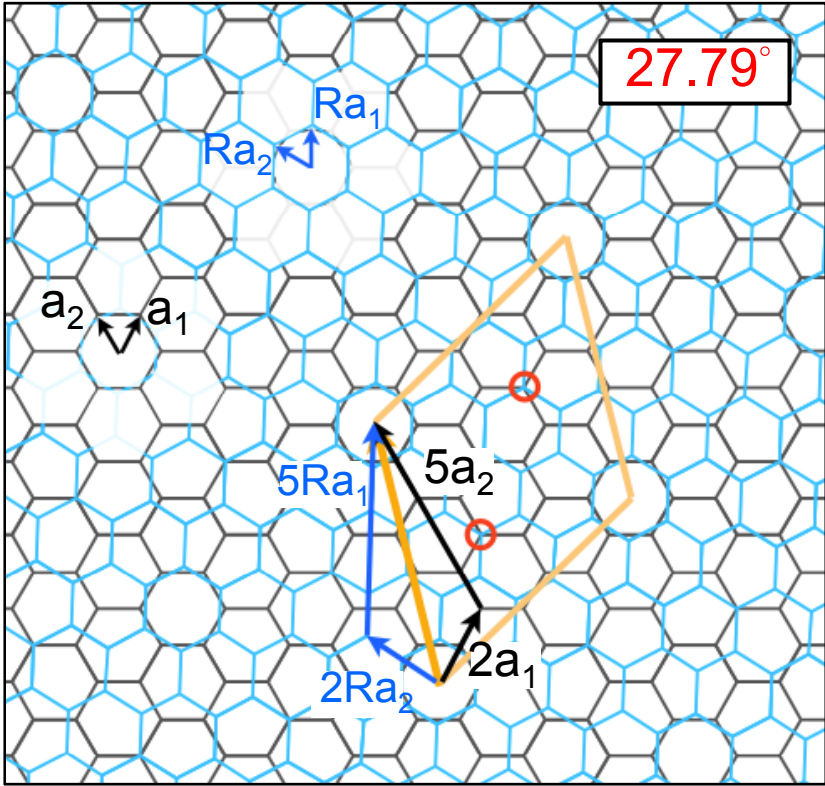


Supercell of twisted bilayer

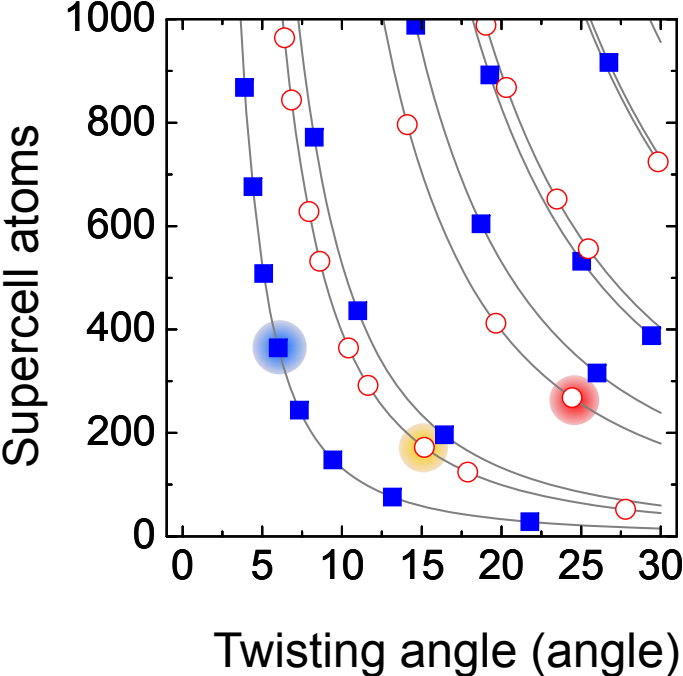
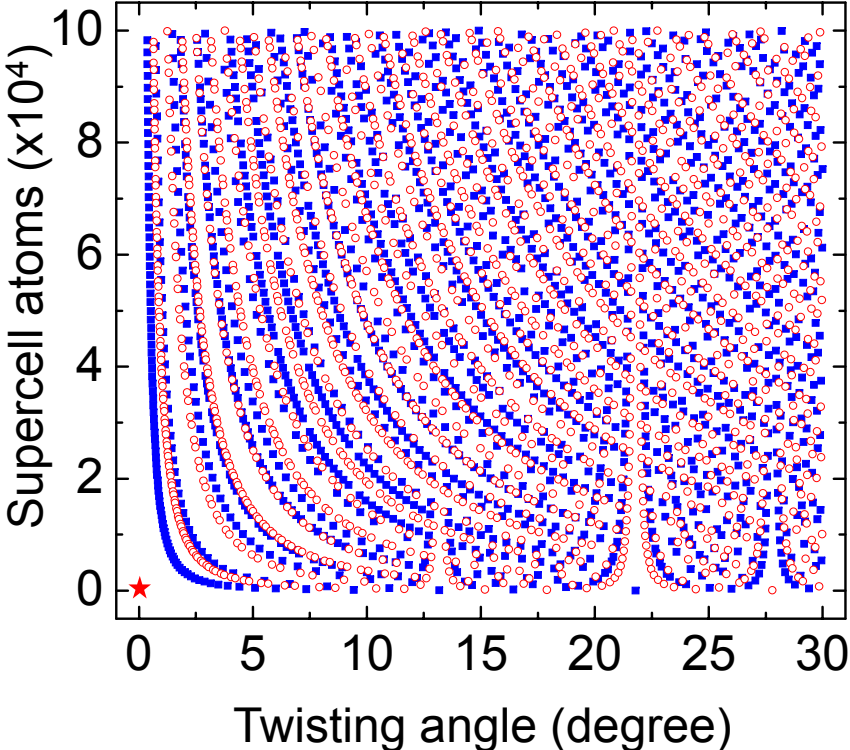
$(n,m)=(3,4)$ K type: $n-m=3i\pm 1$



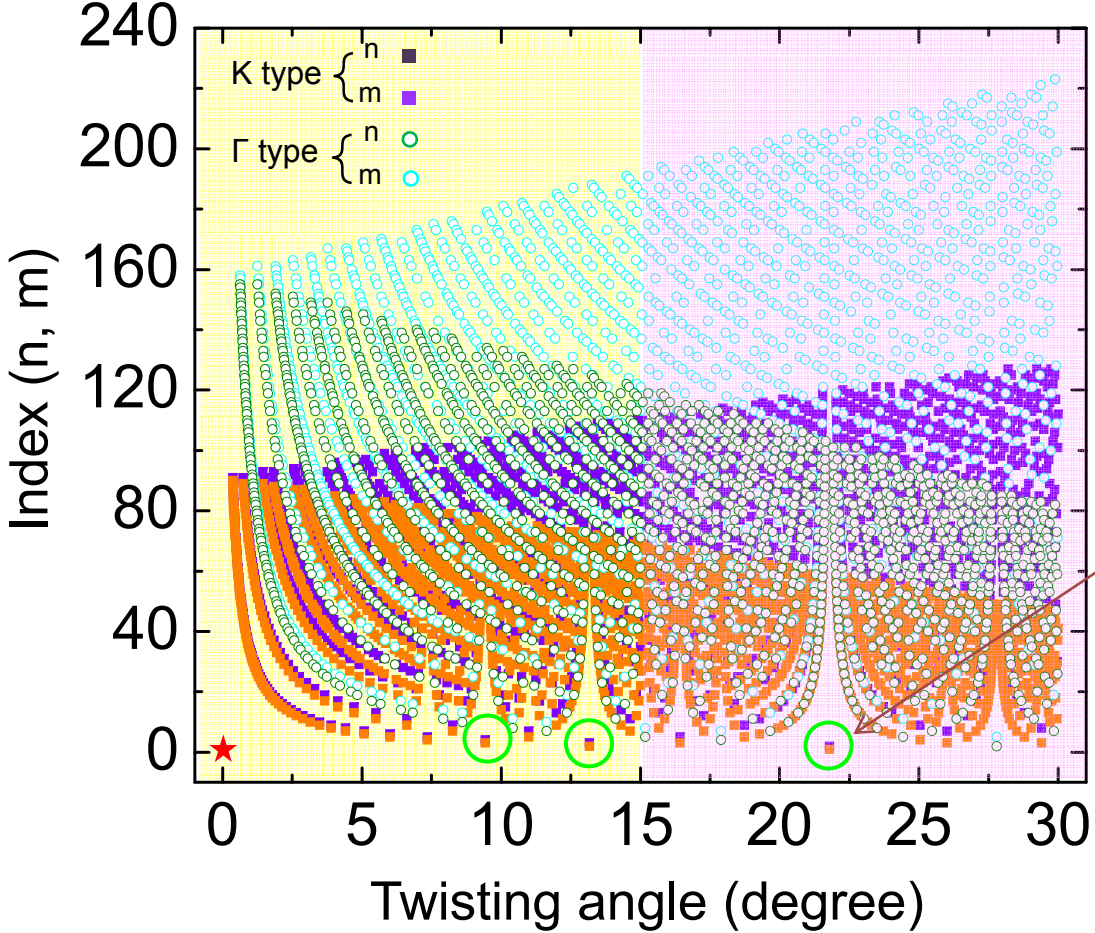
$(n,m)=(5,2)$ Γ type: $n-m=3i$



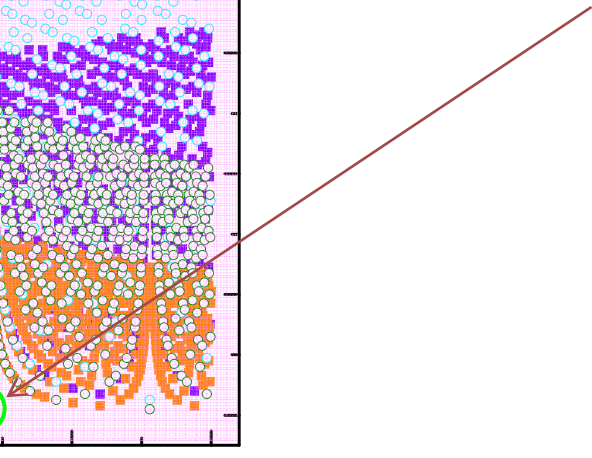
Supercell of twisted bilayer

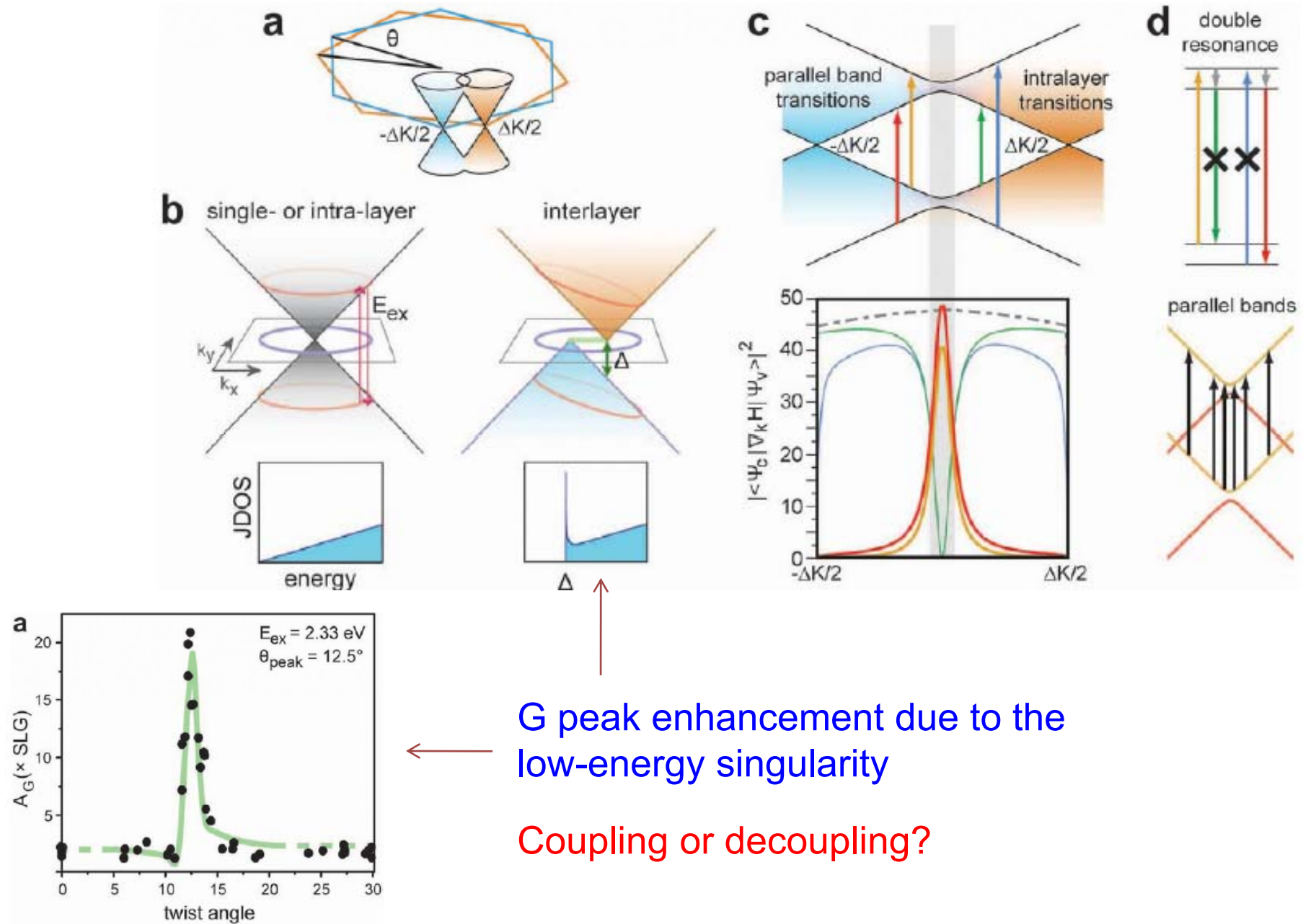


Supercell of twisted bilayer



Coupling or decoupling?





Thank you!

Graphene Growth on Metal Substrates

